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SELECTIVE DEPROTECTION OF ALCOHOLIC AND PHENOLIC SILVL ETHERS

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ABSTRACT: Hydrofluoric acid and tetrabutylammonium fluoride will selectively deprotect alcoholic and phenolic silyl ethers respectively.

One of the most common hydroxyl protecting functions presently in use is the t-butyldimethylsilyl moiety¹. This group is easy to introduce² and of a variety of reagents³ that exist for its removal the most useful is tetrabutylammonium fluoride. More recently⁴ it has been suggested that the use of aqueous hydrofluoric acid is complementary; specifically it allows the removal of the silyl groups from the highly sensitive PGD₂ precursor (1).



We have discovered that these fluorine containing reagents can be used to effect selective desilylation of compounds containing both phenolic and alcoholic t-butyldimethylsilyl ethers. Thus, under <u>carefully controlled conditions</u>, aqueous hydrofluoric acid in acetonitrile selectively regenerates the alcohol function whereas tetrabutylammonium fluoride in tetrahydrofuran liberates the corresponding phenol (Scheme 1). As expected the use of an excess of either reagent eventually results in complete deprotection.



Generally both reactions proceed very cleanly although the deprotections with hydrofluoric acid give reduced yields when the substrates are acid sensitive (Table, entries 4 and 7) or the masked hydroxyl group is sterically hindered (entry 9). In some instances reduced yields were also observed with the fluoride ion-mediated desilylations because concomitant removal of the alcoholic silyl moiety also occurred (entries 3 and 8). However, the use of short contact times (1-2 mins.) and toluene as solvent circumvented these problems and significantly improved the amount of desired product.

Interestingly, both types of products were isolated when the saligenin derivative (entry 3) was treated with tetrabutylammonium fluoride in toluene. This is rationalised on the basis of a fluoride ion-assisted silyl group migration⁵ (Scheme 2) rather than a non-selective deprotection process. This postulate is supported by the observation that where intramolecular silyl migration is not possible (entry 2) then no deprotection of the alcoholic silyl moiety occurs.

Scheme 2



The selective deprotection is also successful with the t-butyldiphenylsilyl group⁶ although more drastic conditions are required to liberate the free alcohol function (Scheme 3). Similar attempts with the trimethylsilyl moiety failed and only fully deprotected compounds were recovered.



Conditions A

2 equivalents of 40% aqueous HF are added to a solution of the substrate in MeCN at either 0^0 or room temperature. When the reaction is complete by t.l.c. analysis (~30 mins.) an excess of 8% $\rm NaHCO_3$ is added and the product is extracted into ether. Purification is carried out by flash chromatography^7 on silica gel.

Conditions B

l equivalent of 1M Bu₄NF/THF is added to a solution of the substrate in THF at 0^0 . After ~15 mins. an excess of aqueous NH₄Cl is added and the product isolated as in A.

8,9 SUBSTRATE		DEPROTECTION CONDITIONS	
	$(R = {}^{t}BuMe_{2}Si)$	A PRODUCT TYPE,(% Yield)	B PRODUCT TYPE,(% Yield)
1.	RO	A (96)	B (96)
2.	RO	A (98)	B (98)
3.	RO	A (98)	B (0-38) ^b B (74) A (4) ^c
4.	Me RO OR	A (37) ^a	B (99)
5.	RQ O''''' OR	A (95)	B (100)
6.	RO	A (95)	B (97)
7.	RO	A (40) ^e	B (100)
8.	Pho Pho	A (46)	B (~50) ^d
			D (94) ⁻
9.	Ro	A (64) B (4)	B (99)

a. Evidence for olefin containing by-products. b. Complete deprotection to the corresponding diol was observed with leq Bu_4NF . 38% Yield of product B was obtained with D.5eq Bu_4NF . c. Toluene/ $0^0/2$ mins. Amount of product A increases with increased reaction time. d. 50% Yield of corresponding diol also produced. e. Toluene/ $0^0/2$ mins.

Table

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 The silyl ethers were prepared by conventional methods (ref. 2) and were obtained in the silve of the silve o
- 6.
- 7.
- 8. yields of 75-99%. All new compounds possessed satisfactory spectroscopic and analytical data.
- 9. Substrates for entries 5-7 were prepared as follows:-





b. H₂/Pd; 95% c. RC1/DMF/Imidazole; 83% a. KF/Al₂O₃; 89% $R = {}^{t}BuMe_{2}Si$

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